Electronic Supplementary Material (ESI) for Physical Chemistry Chemical Physics.

Supporting Information

Atomic Layer Deposited Tungsten Nitride Thin Films as New Lithium-ion Battery Anode

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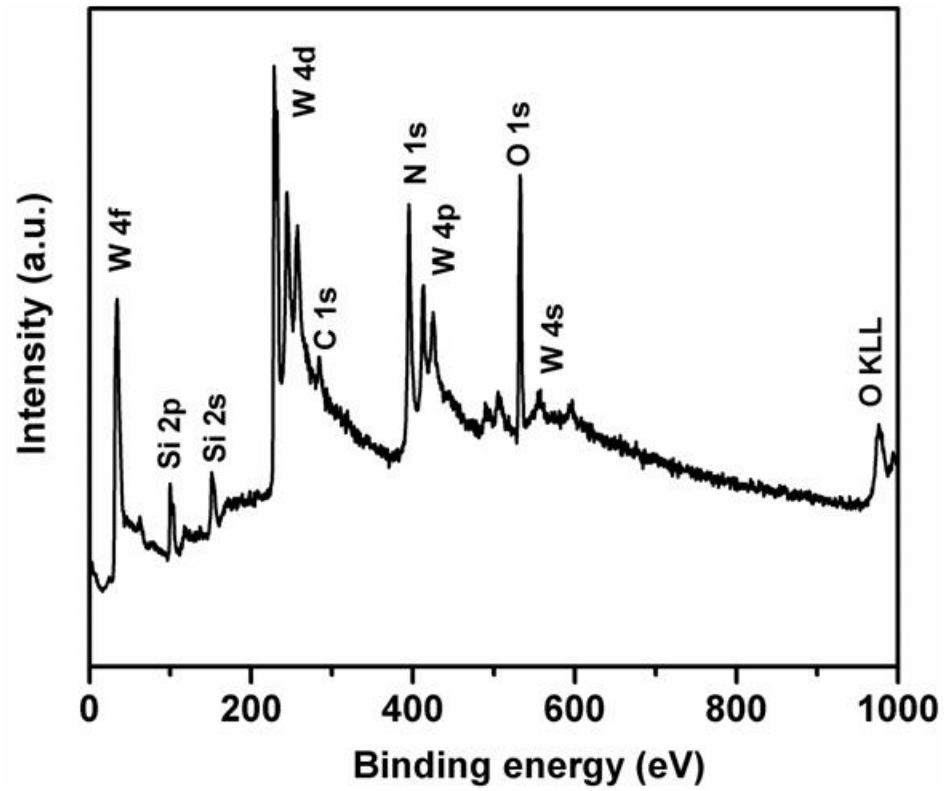

Fig. S1 XPS survey of the as-grown WN_x film in a complete binding energy range of 0-1000 eV

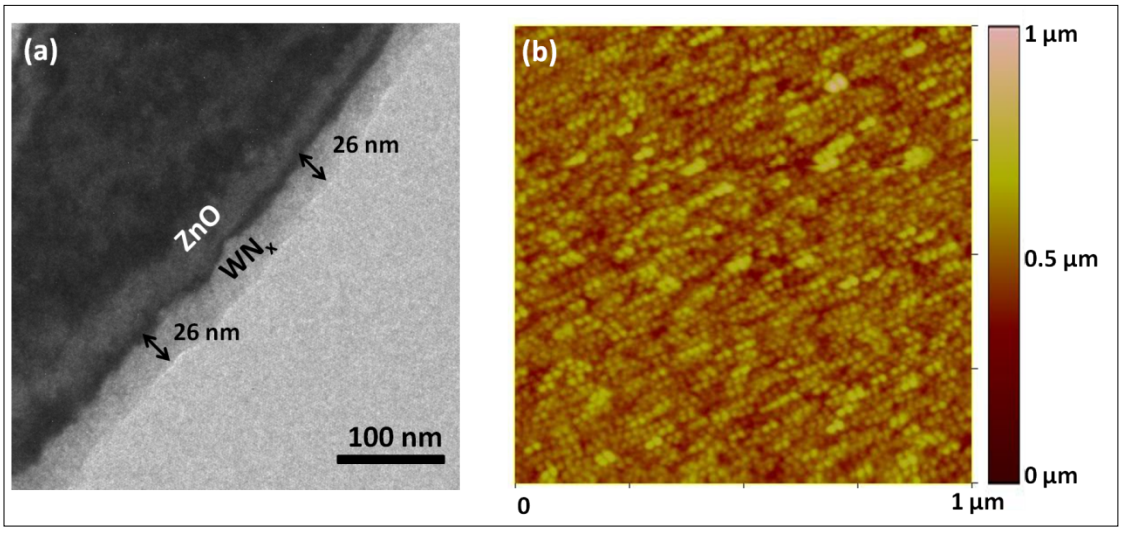

Fig. S2(a) HR-TEM image of ALD WN_x on ZnO and (b) surface AFM of the as-gron film

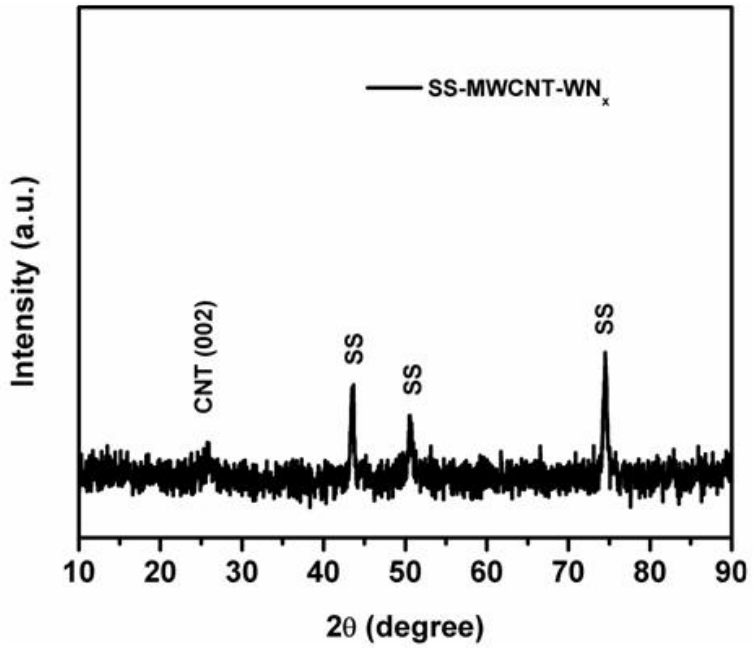

Fig. S3 X-ray diffraction of MWCNT-WN_x film on SS substrate

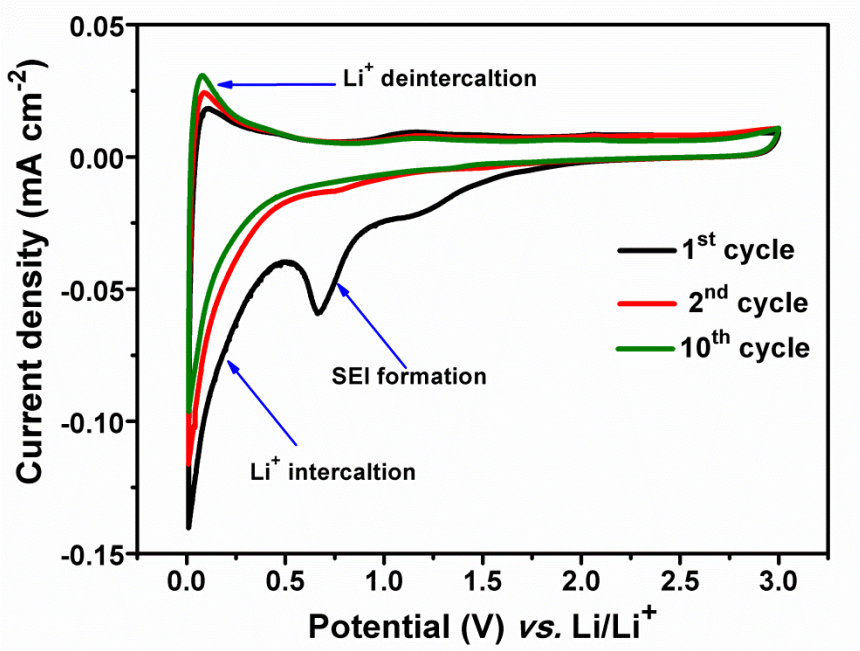

Fig. S4 Cyclic Voltammetry of MWCNT with scan rate of 0.2 mVs^{-1} against Li/Li^+

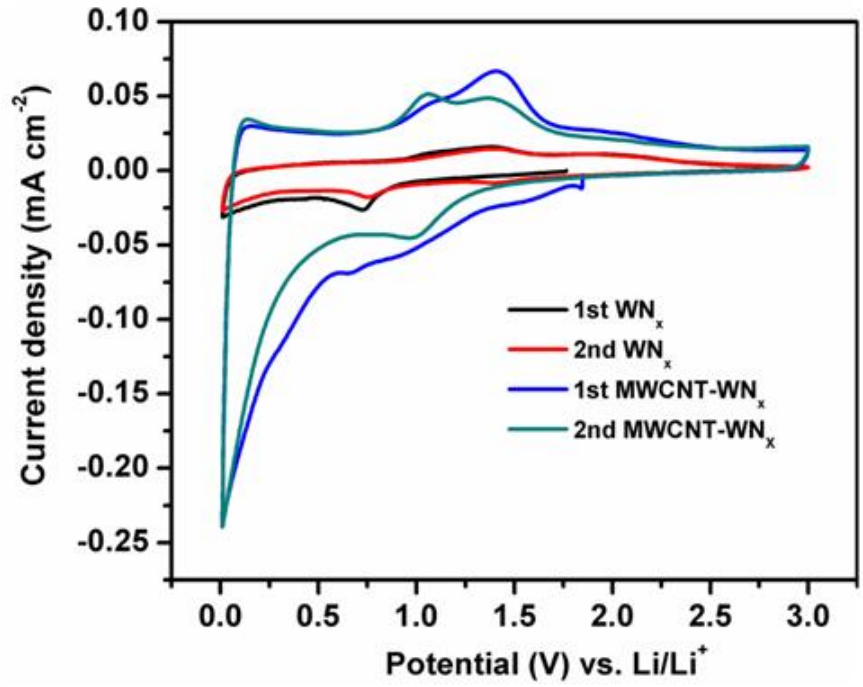

Fig. S5 CV of first two cycles for the as-grown film and film on MWCNT showing the capacity increment of the MWCNT-WN_x assembly

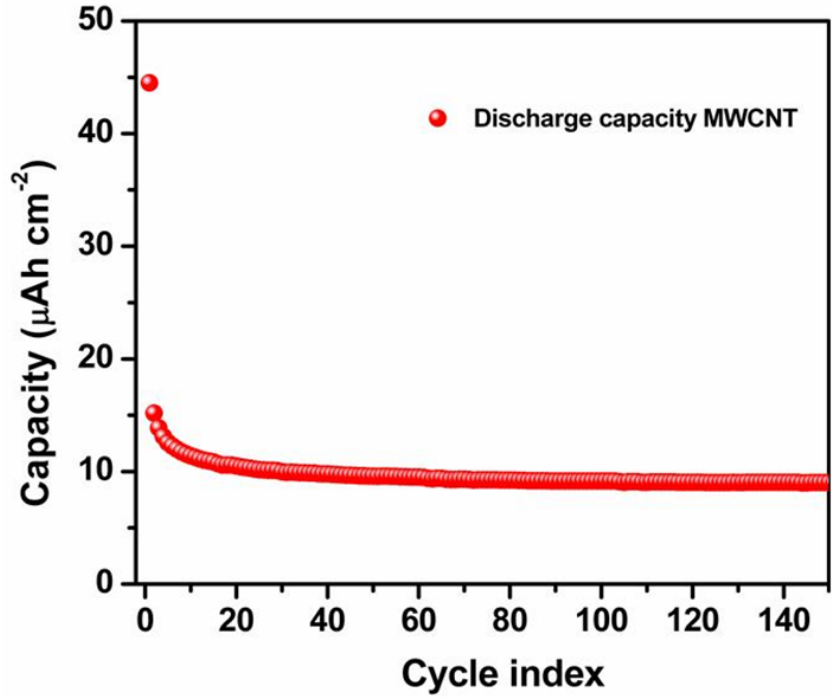

Fig. S6 Discharge capacity with cycle index for MWCNT at a scan rate of 50 μA cm^{-2} against Li/Li^+